

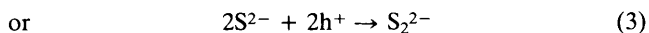
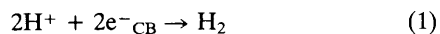
Visible Light-induced Splitting of Hydrogen Sulphide and Thiol Formation in CdS Suspensions

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The effect of hept-1-ene on the photosplitting of H₂S is described.

Recently, several groups have investigated the visible light-induced generation of H₂ from H₂S over aqueous dispersions of CdS particles loaded with catalysts such as Pt,¹ RuO₂,^{2,3} and RuS₂.⁴ In all cases, the test solutions were prepared by addition of Na₂S to water under alkaline conditions. The basic experiments involve band-gap excitation ($\lambda < 520$ nm) to produce electrons in the conduction band and holes in the valence band of the semiconductor. H⁺ is reduced to H₂ by the electrons, equation (1), while S²⁻ is oxidized to S^{2,3} or S₂²⁻,¹ equations (2) and (3).



In general, the initial H₂ production is high but decreases with time owing to accumulation of oxidation products (elemental sulphur and/or polysulphides). Addition of SO₃²⁻ enhances

the H₂ production, presumably because of its reaction with the oxidized species to form S₂O₃²⁻ ions. However, S₂O₃²⁻ in high concentration inhibits H₂ production and its removal is difficult. Consequently, a search for other molecular species which will intercept the oxidation products is warranted.

Since atomic S is known to be extremely reactive towards alkenes in the gas phase, yielding episulphides,⁵ it was felt that it would be of interest to examine the potential of alkenes as interceptors. Hept-1-ene was chosen as the trial alkene. The solvent was acetonitrile previously saturated with H₂S. This solvent promotes solubility of the alkene and consequently reaction of hept-1-ene with the products described in reactions (1), (2), or (3).

CdS powder (Fluka, Puriss) was loaded with 1% RuO₂ by either air oxidation of RuCl₃·3H₂O (Alfa) in the presence of CdS at 360 °C³ or spontaneous decomposition of RuO₄ (Polyscience) in an aqueous suspension of CdS.² Catalysts prepared by either method showed similar activity in aqueous Na₂S solutions. Saturated solutions of H₂S in MeCN were obtained by passing H₂S through the solvent to obtain 0.11 M solutions.

Stirred reaction mixtures (40 ml containing 20 mg CdS/RuO₂) in a Pyrex cell maintained at 21 °C were purged with argon prior to irradiation. The light source was a 450 W Xe arc lamp (Osram). A 10 cm water filter fitted with a Schott 113 glass filter and a 408 nm cut-off filter were used to remove i.r. and u.v. radiation respectively. Quantum yield measurements were obtained using ferrioxalate dosimetry⁶ at 447 nm. H₂ production was measured either by a gas volumeter or by g.c. Sulphur products were analysed by g.c.-mass spectrometry and n.m.r. The CdS/RuO₂ catalyst used in the aqueous Na₂S solution was found to regain its activity when heated under flowing air at 400 °C. Presumably, this removed the deposited sulphur species.

When a suspension of CdS/RuO₂ in acetonitrile saturated with H₂S was irradiated at λ > 408 nm, the initial H₂ production rate was much lower than that observed in the aqueous Na₂S system: Φ($\frac{1}{2}$ H₂) in MeCN *ca.* 0.04 *vs.* Φ($\frac{1}{2}$ H₂) in H₂O *ca.* 0.39.³ Furthermore, the rate dropped off very rapidly with time. This is not surprising since the SH⁻ concentration in basic aqueous solution would be much higher than in acetonitrile. It has been claimed that in aqueous solution the adsorbed SH⁻ ions on CdS/RuO₂ lower its flat-band potential, thus facilitating H₂ production.³

When the H₂S-MeCN solution was irradiated in the presence of 0.05 M hept-1-ene, the H₂ production behaved in a drastically different manner as shown in Figure 1. The initial rate was very low, but remained constant, suggesting that accumulation of sulphur on the catalyst did not occur. Indeed, mass spectral analyses of CCl₄ washings of the solutions containing hept-1-ene showed that only trace quantities of S₈ were present. Analyses of washings from the catalyst used in the absence of heptene indicated significant amounts of S₈.

G.c.-mass spectroscopic analyses of the solutions after irradiation indicated that in the presence of hept-1-ene, sulphur addition products were formed in large quantities. The major product was heptane-1-thiol, comprising about 95% of the total sulphur containing products. The remaining products were heptane-2-thiol (about 4–5%) and diheptyl sulphide, diheptyl disulphide, and diheptyl trisulphide (total < 1%).

The formation of heptane thiols and the depletion of hept-1-ene as a function of irradiation time are shown in

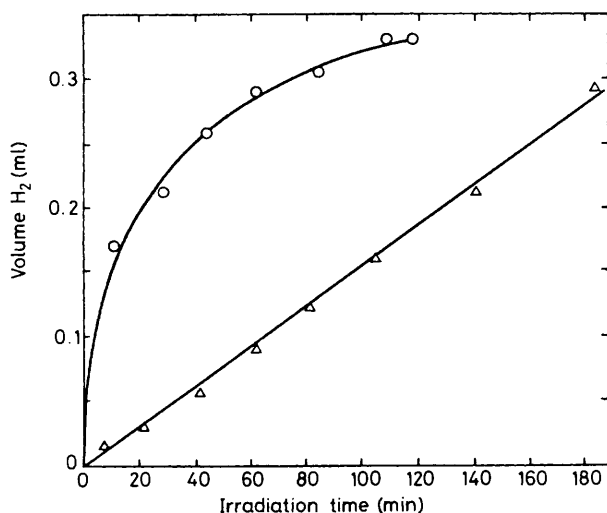
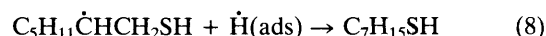
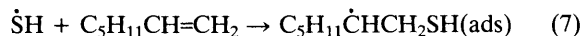
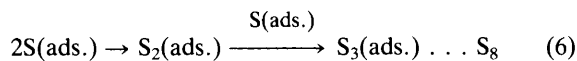
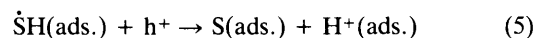
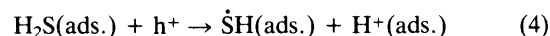


Figure 1. H₂ production as a function of irradiation time in the H₂S saturated MeCN systems: ○ no hept-1-ene present, △ 0.05 M hept-1-ene present.

Figure 2. The rate of thiol formation is initially slow, possibly because of adsorption on the catalyst surface, but eventually rises to a steady value. The concentration of hept-1-ene drops steadily and appears to level off when roughly 70% has been consumed. The fact that the rate of H₂ production did not drop suggests that the apparent levelling off in heptene disappearance is not real. The quantum yields for total thiol and hept-1-ene depletion were measured and found to be 0.15 and 0.50, respectively. The lower quantum yield for thiol formation could be due to adsorption of the thiols on the catalyst surface and/or existence of heptene-consuming reactions that were not observed because they did not yield volatile products that could be detected by g.c.

The production of significant quantities of heptane thiols and the suppression of sulphur formation in the presence of hept-1-ene unambiguously demonstrates that alkenes intercept the oxidation product or products of CdS/RuO₂ catalysed H₂S splitting. However, the alkene apparently also intercepts most of the hydrogen ions, resulting in a low yield of H₂, Φ < 0.01. Based on the mechanism proposed for the electrolysis of H₂S in H₂SO₄,⁷ we suggest the steps (4)–(6) for the CdS/RuO₂ mediated splitting of H₂S in MeCN. H₂ is produced by reaction of the band-gap electrons with H⁺ formed in reactions (4) and (5).

The alkene could react with either the ŠH moiety to form a radical or with S to form an episulphide. Radical formation would lead to thiol production as shown in steps (7) and (8).



A chain reaction involving abstraction of Ĥ from H₂S, as in

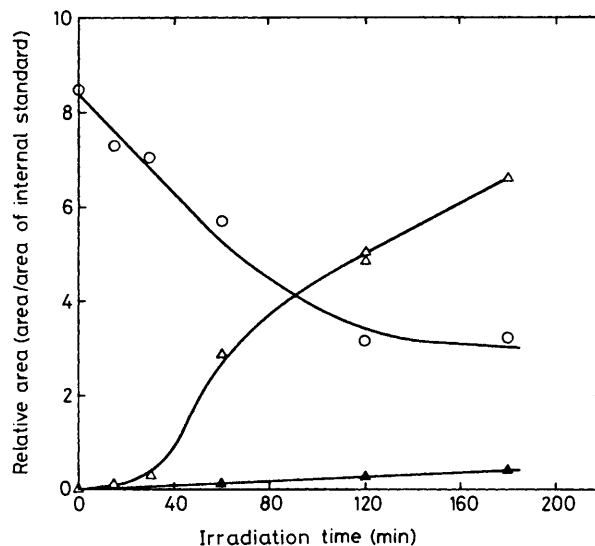
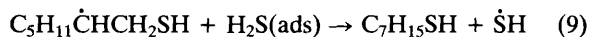
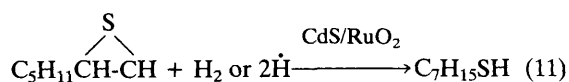
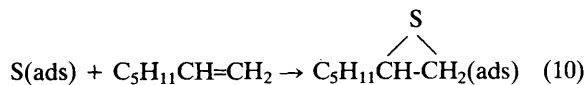


Figure 2. Formation of heptane thiols and depletion of hept-1-ene as a function of irradiation time in the H₂S saturated MeCN system, [hept-1-ene] = 0.05 M: ○ hept-1-ene, △ heptane-1-thiol, ▲ heptane-2-thiol.

the case of the u.v.-initiated addition of H₂S to alkene,⁸ seems unlikely, since reaction (9) implies no effect on H₂ production.



Episulphide formation followed by addition of H₂ or 2H would lead to thiol formation, equations (10) and (11). The relative importance of $\dot{\text{S}}\text{H}$ and S addition is of interest, since it might be possible to prevent addition of H₂ to the episulphide and so preserve the more interesting product. However, at present there is no evidence to differentiate the two possibilities.



The overall reaction reported here concerns the light-induced addition of H₂S to a double bond under unusual circumstances: only visible light ($\lambda > 400$ nm) was employed, and the process is apparently not a chain reaction. This is one

of very few CdS catalysed reactions involving organic molecules to be reported.^{9,10}

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